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THE UNITED STATES PATENT AND TRADEMARK OFFICE

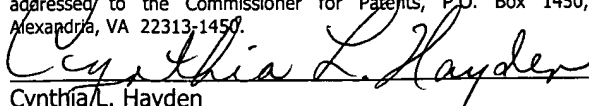
In re Applicant:	Aaron O. Vanderpool et al.	§	Art Unit:	2891
Serial No.:	10/789,851	§	Examiner:	Asok K. Sarkar
Filed:	February 26, 2004	§	Atty Docket:	ITL.1078US P18386
For:	Implanting Carbon to Form P-Type Source Drain Extensions	§	Assignee:	Intel Corporation

Mail Stop **Amendment**
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REPLY TO OFFICE ACTION

Sir:

In response to the office action mailed August 16, 2005, please amend the above-referenced patent application as follows:

Date of Deposit: November 2, 2005
I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Cynthia L. Hayden